

09/806852

U.S. UTILITY Patent Application

APPLICATION NO. 09/806852	CONT/PRIOR D F	CLASS 430	SUBCLASS 270.1	ART UNIT 1756 1752	EXAMINER LEE, S. J.
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Photosensitive polysilazane composition and method of forming patterned polysilazane film

PTO-2040  
12/89

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